

General Program				
Date	Venue	Time	Event	
September 5	Panorama	15.00-18.00	Registration (Lobby)	
September 6	Panorama	8.00-18.00	Registration (Lobby)	
		9.00-9.35	Opening ceremony (Central Hall)	
		9.35-10.20	Plenary lecture (Central Hall)	
		10.20-10.40	Coffee break	
		10.40-11.25	Plenary lecture (Central Hall)	
		11.25-12.00	Invited lecture (Central Hall)	
		12.00-13.30	Lunch	
		13.30-15.35	Oral Session OS-1-1, Section 1 (Hall A)	Oral Session OS-2-1, Section 2 (Hall B)
		15.35-15.55	Coffee break	
		15.55-18.00	Oral Session OS-4-1, Section 4 (Hall A)	Oral Session OS-3-1, Section 3 (Hall B)
		18.00-21.00	Welcome party	
September 7	Panorama	9.00-18.00	Registration (Lobby)	
		9.00-9.45	Plenary lecture (Central Hall)	
		9.45-10.20	Invited lecture (Central Hall)	
		10.20-10.30	Photographing	
		10.30-10.50	Coffee break	
		10.50-11.25	Invited lecture (Central Hall)	
		11.25-12.00	Invited lecture (Central Hall)	
		12.00-13.30	Lunch	
		13.30-15.35	Oral Session OS-1-2, Section 1 (Hall A)	Oral Session OS-2-2, Section 2 (Hall B)
		15.35-15.55	Coffee break	
		15.55-18.00	Oral Session OS-4-2, Section 4 (Hall A)	Oral Session OS-3-2, Section 3 (Hall B)

Date	Venue	Time	Event	
September 8	Panorama	9.00-12.00	Registration (Lobby)	
		09.00-10.10	Oral Session OS-1-3, Section 1 (Hall A)	Oral Session OS-2-3, Section 2 (Hall B)
		10.10-10.30	Coffee break	
		10.30-12.00	Oral Session OS-4-3, Section 4 (Hall A)	Oral Session OS-3-3, Section 3 (Hall B)
	IEP	12.00-14.00	Lunch, transfer to IEP	
		14.00-15.30	Poster Session, Sections 1 and 4 (IEP)	IEP excursion for Sections 2 and 3
		15.30-17.00	Poster Session, Sections 2 and 3 (IEP)	IEP excursion for Sections 1 and 4
September 9	Panorama	9.00-12.00	Registration (Lobby)	
		09.00-10.25	Oral Session OS-1-4, Section 1 (Hall A)	Oral Session OS-2-4, Section 2 (Hall B)
		10.25-10.40	Coffee break	
		10.40-12.00	Oral Session OS-4-4, Section 4 (Hall A)	Oral Session OS-2-5, Section 2 (Hall B)
		12.00-13.30	Lunch	
		13.30-18.00	Excursion	
		18.00	Gala Dinner	
September 10	Panorama	9.00-12.00	Registration (Lobby)	
		09.00-10.25	Oral Session OS-1-5, Section 1 (Hall A)	Oral Session OS-2-6, Section 2 (Hall B)
		10.25-10.40	Coffee break	
		10.40-12.00	Oral Session OS-1-6, Section 1 (Hall A)	
		12.00-12.30	Closing ceremony	

Sections

1. Fundamental processes in low-temperature plasma:

low and high pressure discharges, near-electrode phenomena, radiation, ultrafast processes, diagnostics.

2. Gas-discharge methods for surface modification and coating deposition:

surface modification, ion implantation, combined methods of surface treatment.

3. Plasma-chemical, electrophysical and laser technologies:

environmental applications, production of nanopowders and functional materials.

4. Sources of low-temperature plasma:

generators of continuous, pulse-periodic and pulsed action, gas switches, power supply.

Plenary lecture: 45 min (40+5 minutes for questions)

Invited lecture: 35 min (30+5)

Invited report: 25 min (20+5)

Oral report: 20 min (15+5)